

Title (en)

OXYGEN-ARGON GAS MIXTURE FOR PRECLEANING IN VACUUM PROCESSING SYSTEM

Title (de)

SAUERSTOFF-ARGON GASGEMISCH ZUR VORREINIGUNG EINES VAKUUMPROZESSSYSTEMS

Title (fr)

MELANGE DE GAZ ARGON-OXYGENE PERMETTANT UN PRE-NETTOYAGE DANS UN SYSTEME DE TRAITEMENT SOUS VIDE

Publication

EP 1086260 A1 20010328 (EN)

Application

EP 99921909 A 19990511

Priority

- US 9910392 W 19990511
- US 7658998 A 19980512

Abstract (en)

[origin: WO9958739A1] A method for cleaning, or pre-cleaning, a process objet, such as a substrate, uses a process gas, such as argon, mixed with a quantity of oxygen. The process gas sputter etches material from the surface of the process object to clean or remove oxides, or other contaminants, therefrom. The oxygen reacts with the etched material to form stoichiometrically balanced compounds that deposit in a smooth film on a process kit. The process kit is periodically removed and replaced after a predetermined number of process objects have been processed, or cleaned.

IPC 1-7

C23C 16/44; **C23C 16/02**; **C23C 14/02**; **H01J 37/32**; **H01L 21/00**; **B08B 7/00**

IPC 8 full level

B08B 7/00 (2006.01); **C23C 14/02** (2006.01); **C23C 16/02** (2006.01); **C23C 16/44** (2006.01); **H01J 37/32** (2006.01); **H01L 21/302** (2006.01); **H01L 21/3065** (2006.01); **H01L 21/3213** (2006.01)

CPC (source: EP KR)

C23C 14/022 (2013.01 - EP); **C23C 16/0245** (2013.01 - EP); **C23C 16/44** (2013.01 - KR); **H01J 2237/335** (2013.01 - EP); **H01L 21/32136** (2013.01 - EP)

Citation (search report)

See references of WO 9958739A1

Designated contracting state (EPC)

BE DE GB NL

DOCDB simple family (publication)

WO 9958739 A1 19991118; EP 1086260 A1 20010328; JP 2002514831 A 20020521; KR 20010043555 A 20010525

DOCDB simple family (application)

US 9910392 W 19990511; EP 99921909 A 19990511; JP 2000548527 A 19990511; KR 20007012675 A 20001113